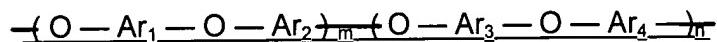
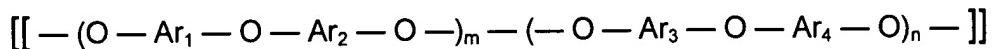


Appl. No. 10/046,615
Amendment dated October 14, 2003
Reply to Office Action of April 11, 2003

Amendments To The Abstract:

Please replace the Abstract of the Disclosure with the following amended Abstract of the Disclosure:

A poly(arylene ether) polymer includes polymer repeat units of the following structure:



where Ar_1 , Ar_2 , Ar_3 , and Ar_4 are identical or different aryl radicals, m is 0 to 1, n is 1- m , and at least one of the aryl radicals is grafted to at least one unsaturated group that is non-aromatic and is adapted to crosslink at a curing temperature below 200°C without producing volatiles during curing and without providing functional groups after curing. Cured films containing the polymer can have a T_g from 160°C to 180°C, a dielectric constant below 2.7 with frequency independence, and a maximum moisture absorption of less than 0.17 wt%. Accordingly, the polymer is especially useful in interlayer dielectrics and in die-attach adhesives.